

AN 2002-323696 [36] WPIDS  
 DNC C2002-094211 [36]  
 DNN N2002-254023 [36]  
 TI Electrode wire for wire electrical discharge processings, comprises  
 specific amount of tin and indium, remainder of copper and unavoidable  
 impurity  
 DC M11; M23; M26; P54  
 IN KIMURA T; KURODA H; MATSUZAKI H; NAGAI T; SATO T; SAWAHATA K  
 PA (HITD-C) HITACHI CABLE LTD  
 CYC 1  
 PIA JP 2002047520 A 20020215 (200236)\* JA 6[0] <--  
 JP 3941352 B2 20070704 (200744) JA 9  
 ADT JP 2002047520 A JP 2000-233175 20000728; JP 3941352 B2 JP  
 2000-233175 20000728  
 FDT JP 3941352 B2 Previous Publ JP 2002047520 A  
 PRAI JP 2000-233175 20000728  
 AB JP 2002047520 A UPAB: 20050525  
 NOVELTY - The electrode wire comprises 0.01-2.40 weight% of each of  
 indium and tin, and remainder of copper and unavoidable impurity.  
 DETAILED DESCRIPTION - An INDEPENDENT CLAIM is also included for  
 the electrode wire manufacturing method.  
 USE - For wire electrical discharge processings of hard cutting  
 materials such as graphite and sintered metal.  
 ADVANTAGE - The electrode wire of desired diameter has excellent  
 electrical discharge processing characteristics and favorable wire drawing  
 property.